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Electronic Version v1.1

Stylesheet Version v1.1.0

Title of
Invention

STRUCTURE AND METHOD OF FORMING BIPOLAR TRANSISTOR HAVING A SELF-ALIGNED RAISED EXTRINSIC BASE USING SELF-ALIGNED ETCH STOP LAYER

Application Number :

Date :

First Named Applicant: Marwan H. Khater

Confirmation Number:

Attorney Docket Number: FIS920030412US1

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Submitted By:	Elec. Sign.	Sign. Capacity
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Documents being submitted:	Files
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us-assignment	FIS920030412US1-usassn.xml
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us-fee-sheet	FIS920030412US1-usfees.xml
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	us-fee-sheet.dtd
us-ids	FIS920030412US1-usidst.xml
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	us-ids.xsl
us-declaration	FIS920030412US1Declaration3.tif
application-body	FIS920030412US1-trans.xml
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Comments	
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